



L Number	Hits	Search Text	DB	Time stamp
number		//!! 4020(61!!) /!! 40500(1!!)	TYO DAM:	2001/11/10
-	12	(("4239661") or ("4958061") or	USPAT;	2001/11/10
		("5286678") or ("5288651") or ("5290361")	US-PGPUB	22:53
		or ("5447568") or ("5466389") or		
		("5783495") or ("5972862") or ("5855811")		
•		or ("5679171") or ("6096650")).PN.		
<del>-</del>	4847	ammonium adj fluoride	USPAT;	2001/11/08
		_	US-PGPUB	16:30
' <b>_</b>	99	(ammonium adj fluoride) with cleaning	USPAT;	2001/11/10
		, , , , , , , , , , ,	US-PGPUB	21:57
_	58	tetra\$1alkyl adj ammonium adj fluoride	USPAT;	2001/11/08
			US-PGPUB	15:28
_	1	("5780406").PN.	USPAT;	2001/11/08
	1	\ 3700400 \ 2.24.	US-PGPUB	15:28
_	175	sheet\$1by\$1sheet	USPAT;	2001/11/08
	1/3	Sheectingtimeec	US-PGPUB	15:35
	30	sheet\$1by\$1sheet and semiconductor		2001/11/08
-	30	sneet and semiconductor	USPAT;	
	1	/ . N E A 1 N A 1 . N	US-PGPUB	15:36
-	14	(sheet\$1by\$1sheet and semiconductor) and	USPAT;	2001/11/08
		cleaning	US-PGPUB	15:36
-	1	("5402807").PN.	USPAT;	2001/11/08
	1		US-PGPUB	16:30
_	91	(ammonium adj fluoride) with peroxide	USPAT;	2001/11/08
	1		US-PGPUB	16:31
_	86	((ammonium adj fluoride) with peroxide)	USPAT;	2001/11/08
	1	with (hydrogen adj peroxide)	US-PGPUB	16:31
_	72	(((ammonium adj fluoride) with peroxide)	USPAT;	2001/11/08
	1	with (hydrogen adj peroxide)) and	US-PGPUB	16:32
	1	semiconductor	05 10105	10.52
_	15	((((ammonium adj fluoride) with peroxide)	USPAT;	2001/11/08
_	13		US-PGPUB	16:32
		with (hydrogen adj peroxide)) and	US-PGPUB	16:32
	404	semiconductor) and (cleaning near wafer)		2001 (11 (00
_	404	("438/745").CCLS.	USPAT;	2001/11/08
			US-PGPUB	17:46
_	205	("438/689").CCLS.	USPAT;	2001/11/08
			US-PGPUB	17:51
-	221	("438/704").CCLS.	USPAT;	2001/11/08
			US-PGPUB	17:57
-	367	("134/1.3").CCLS.	USPAT;	2001/11/08
			US-PGPUB	18:12
_	761	("252/79.1").CCLS.	USPAT;	2001/11/08
			US-PGPUB	18:13
_	323	("252/79.5").CCLS.	USPAT;	2001/11/10
			US-PGPUB	19:29
<u>-</u>	1	("5135608").PN.	USPAT;	2001/11/08
	1	, ,	US-PGPUB	18:25
_	323	("252/79.5").CCLS.	USPAT;	2001/11/10
	525	, 202/15.0 /.0025.	US-PGPUB	19:38
_	761	("252/79.1").CCLS.	USPAT;	2001/11/10
· '	,01	\ 232/19.1  .CCLS.	· ·	1
_	350	("E10/17E") CCT C	US-PGPUB	19:57
-	356	("510/175").CCLS.	USPAT;	2001/11/10
		/# 400 /000 # 1 = = = =	US-PGPUB	19:58
_	60	("438/908").CCLS.	USPAT;	2001/11/10
			US-PGPUB	22:55
-	89	("438/907").CCLS.	USPAT;	2001/11/10
			US-PGPUB	20:34
-	75	(("438/907").CCLS.) not	USPAT;	2001/11/10
		(("438/908").CCLS.)	US-PGPUB	20:34
_	1	("5277835").PN.	DERWENT	2001/11/10
	_	`		21:19
_	2	(U11-A09 and U11-C04A1 and U11-C07B and	DERWENT	2001/11/10
		U11-C07C3).epi.	201111111	21:21
_	2142		DEDMENT	
_	3142	L04-C07C.cpi.	DERWENT	2001/11/10
		TO4 0070	DEDITE:	21:21
-	208	L04-C07C.cpi. and ammonium	DERWENT	2001/11/10
				21:21
_	96	(L04-C07C.cpi. and ammonium) and fluoride	DERWENT	2001/11/10
				21:21
-	92	(L04-C07C.cpi. and ammonium) and	DERWENT	2001/11/10
		(ammonium near fluoride)		21:21

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-	13		DERWENT	2001/11/10
		(ammonium near fluoride)) and clean\$6		21:31
-	1	(B05D001/00 and C09K013/08 and	EPO; JPO;	2001/11/10
		C23F001/24 and H01L021/306 and	DERWENT	21:32
		H01L021/308 and H01L021/31 and		
		H01L021/311).ipc.		
-	1	(B05D001/00 and C09K013/08 and	EPO; JPO;	2001/11/10
		C23F001/24 and H01L021\$).ipc.	DERWENT	21:33
-	1	(B05D001\$ and C09K013/08 and	EPO; JPO;	2001/11/10
		C23F001/24 and H01L021\$).ipc.	DERWENT	21:33
-	1	(B05D\$\$ and C09K013/08 and C23F001/24	EPO; JPO;	2001/11/10
		and H01L021\$).ipc.	DERWENT	21:33
-	3	(B05D\$\$ and C23F001/24 and	EPO; JPO;	2001/11/10
		H01L021\$).ipc.	DERWENT	21:34
-	169	(ammonium adj fluoride) and clean\$6	EPO; JPO;	2001/11/10
			DERWENT	21:35
-	17	((ammonium adj fluoride) and clean\$6) and	EPO; JPO;	2001/11/10
		peroxide	DERWENT	21:35
-	1	("5277835").PN.	USPAT;	2001/11/10
			US-PGPUB	21:53
_	16	((ammonium adj fluoride) with cleaning)	USPAT;	2001/11/10
		and ultrasonic	US-PGPUB	21:58
-	1	5135608.pn.	USPAT;	2001/11/10
	_		US-PGPUB	22:53
-	6	multi\$1chamber and sheet\$1by\$1sheet	USPAT;	2001/11/10
			US-PGPUB	22:57
-	942	multi\$1chamber and continuous	USPAT;	2001/11/10
		l	US-PGPUB	22:58
-	129	(multi\$1chamber and continuous ) and	USPAT;	2001/11/10
		(continuous near process\$6)	US-PGPUB	22:59
-	254	(clean\$5 near wafer) with oxide	USPAT;	2001/11/13
			US-PGPUB	08:35
-	7	((clean\$5 near wafer) with oxide) with	USPAT;	2001/11/13
		peroxide	US-PGPUB	08:36
-	378	((silicon adj oxide) with etch\$6) and	USPAT;	2001/11/13
		(ammonium adj fluoride)	US-PGPUB	08:43
-	292	(((silicon adj oxide) with etch\$6) and	USPAT;	2001/11/13
		(ammonium adj fluoride)) and (etch\$6 with	US-PGPUB	08:44
		(ammonium adj fluoride))		
-	48	((((silicon adj oxide) with etch\$6) and	USPAT;	2001/11/13
		(ammonium adj fluoride)) and (etch\$6 with	US-PGPUB	08:48
		(ammonium adj fluoride))) and (hydrogen		
		adj peroxide)		
] -	86	(ammonium adj fluoride) with (hydrogen	USPAT;	2001/11/13
		adj peroxide)	US-PGPUB	08:49
-	55	(("3876468") or ("3911169") or	USPAT;	2001/11/13
		("4087367") or ("4171242") or ("4329435")	US-PGPUB	09:37
		or ("4381341") or ("4845050") or		
		("4876042") or ("4962063") or ("5043299")	ł	]
		or ("5089084") or ("5135608") or		
		("5158616") or ("5178682") or ("5229323")	1	
		or ("5268069") or ("5277835") or		
		("5296093") or ("5320709") or ("5360748")		
		or ("5374581") or ("5376223") or		
		("5380682") or ("5402807") or ("5412240")		
		or ("5413664") or ("5454901") or	[	
		("5478436") or ("5478780") or ("5494494")		
	1	or ("5496485") or ("5498293") or		
		("5503173") or ("5512320") or ("5530266")		]
		or ("5578520") or ("5630904") or		
		("5679171") or ("5716495") or ("5716535")		
		or ("5779520") or ("5780406") or		
		("5803956") or ("5858106") or ("5858863")		]
		or ("5968848") or ("5972123") or		
	ĺ	("5990060") or ("6030932") or ("6068788")		
	İ	or ("6117350") or ("6145519") or		]
	}	("6224785") or ("6284721") or		
	-	("6294027")).PN.	IICDAM.	2001/11/12
-	1		USPAT;	2001/11/13
L	L	TMAF) with (hydrogen adj peroxide)	US-PGPUB	09:39